

Title (en)

Composition sensitive to IR radiation and to heat and lithographic plate coated with this composition

Title (de)

Infrarotstrahlungs- und wärme-empfindliche Zusammensetzung, und lithographische Druckplatte, die mit dieser Zusammensetzung beschichtet ist

Title (fr)

Composition sensible aux rayons infrarouges et à la chaleur et plaque lithographique préparée avec cette composition

Publication

EP 1072404 A1 20010131 (EN)

Application

EP 00202653 A 20000724

Priority

- EP 00202653 A 20000724
- EP 99830489 A 19990730

Abstract (en)

A heat-sensitive composition of the positive type comprising a polymeric binder and a solubility inhibitor, wherein the said solubility inhibitor is a hydroxylated acrylic polymer, a hydroxylated acrylic copolymer or of a derivative thereof wherein some hydroxyl groups have been esterified by a carboxylic acid or a reactive derivative thereof.

IPC 1-7

B41C 1/10; **B41M 5/36**

IPC 8 full level

B41C 1/10 (2006.01); **B41M 5/36** (2006.01)

CPC (source: EP)

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Citation (search report)

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